Research Article

The Role of Solvent Environment on the Optical Behavior of Chemically Synthesized Silicon Nanoparticles

Rawabi M. Al Mohaimeed,† Anees A. Ansari,‡ and Abdullah Aldwayyan

1Department of Physics, College of Sciences, King Saud University, Riyadh 11451, Saudi Arabia
2King Abdullah Institute for Nanotechnology, King Saud University, Riyadh 11451, Saudi Arabia

Correspondence should be addressed to Abdullah Aldwayyan; dwayyan@ksu.edu.sa

Received 23 November 2017; Revised 8 February 2018; Accepted 20 February 2018; Published 10 April 2018

Academic Editor: Javier Garcia-Guinea

Copyright © 2018 Rawabi M. Al Mohaimeed et al. This is an open access article distributed under the Creative Commons Attribution License, which permits unrestricted use, distribution, and reproduction in any medium, provided the original work is properly cited.

Silicon nanoparticles (Si-NPs) were prepared by solution-based chemical etching method. Optical characteristics of the as-prepared Si-NPs were investigated in different polar and nonpolar organic solvents. The emission and absorption properties of Si-NPs were tuned by altering the environment (solvents). The variation in absorption coefficient was observed because of the solvent interaction nature of Si-NPs. Si-NPs in polar aprotic and nonpolar solvents manifested good luminescence under UV excitation. PL intensities were observed to be depending on etched cross-section area on wafer surface. The results show a linear dependence of the refractive index (n) on wavelength (λ). The nature of solvents altered the luminescence efficiency of Si-NPs when examining under UV lamp. The emission and absorption properties of Si-NPs were tuned by altering the environment (solvents) through electrostatic interaction of various organic solvents with the Si-NPs. The band shapes of the Si-NPs show remarkable changes in passing from noncoordinating solvent (chloroform) to various coordinating solvents, which was the result of change in the environment around Si-NPs in various solutions.

1. Introduction

Silicon nanoparticles (Si-NPs) can be classified into a family of discrete sizes that includes 1.0, 1.67, 2.15, 2.9, and 3.7 nm diameters [1]. Photoluminescence excitation spectroscopy measured the four smallest highest occupied molecular orbital (HOMO) lowest unoccupied molecular orbital (LUMO) band gaps of 3.44, 2.64, 2.39, and 2.11 eV, while emission spectroscopy shows that they are ultrabright UV/blue, green, yellow, and red luminescent particles with band peaks at ~410, 540, 570, and 600 nm [2, 3]. Furthermore, investigation of Si-NPs in nonlinear optical response under a variety of multiphoton infrared excitation including 1.06, 1.3, and 4.9 μm radiation, requiring 3, 3, and 15 photon processes to achieve direct gap excitation of carriers, the interest has been dampened by the fact that the luminescence is wide band and of low quantum efficiency. Silicon-based nanomaterials are some new photoelectronic and informational materials developed rapidly in recent years. For a long time, silicon has been considered as unsuitable for optoelectronic applications because bulk silicon emits hardly any useful light due to its indirect band gap nature. This opinion was deeply changed after the discovery of bright emission from porous silicon and NPs. The possibility of constructing optoelectronic devices, Si-based integrated circuits, and sensors based on silicon has generated tremendous interest in the preparation and characterization of light-emitting Si-NPs. Although, the first porous silicon layer was observed by Uhlir in 1956 [4] and later by Turner [5], it was only during Canham in 1990 after reporting about room temperature luminescence that there began significant interest in this material [6]. The main obstacle of using Si-NPs in optical applications is the much slower recombination rate (excitation lifetime is 4-5 orders of magnitude larger than in some direct band gap quantum dots).

It is fact that the luminescence properties of Si-NPs are size dependent and multicolored, which have exciting potential applications as fluorescent tags for biological imaging [7–9] and a great variety of NPs are currently
used for bioanalysis including QDs [10]. Si-NPs are much brighter and more stable for photobleaching [11] than organic dyes [12] with higher ability to enhance spectra, which make emission at multiple wavelengths (from particles of different sizes) excited by a single source possible. Si-NPs have a wide range of applications in various fields such as electronics, fuel cells, batteries, agriculture, food industry, and medicines. Si-NPs can vastly improve mechanical, magnetic, electrical, and catalytic properties compared to conventional bulk Si materials [13–15]. Si-NPs are a promising material to use as biological labels [16]; metal NPs are usually considered harmful as they become transparent to cell dermis. Toxicity of NPs also appears predominant owing to their high surface area and enhanced surface activity. Si-NPs are less toxic than QDs; they offer higher quantum luminescence efficiency than the latter in composites [17], as well as prove to be more stable to the environment.

Previously, some coworkers in our laboratories studied the emission spectra that Si-NPs fabricated by chemical etching technique in different organic solvents [12, 18, 19]. They examine the effects of solvents and temperature on the optical absorption spectra and luminescence spectra of Si-NPs, in which the emission and absorption properties of Si-NPs were tuned by altering the environment (solvents) because of electrostatic interaction of various organic solvents with Si-NPs [19]. The band shapes of the Si-NPs show remarkable changes in passing from noncoordinating solvent (chloroform) to various coordinating solvents, which is the result of change in the environment around Si-NPs in various solutions and suggests coordination of solvent molecule(s), in some cases.

In this study, our main aim is to investigate the optical properties of chemical etching method prepared for Si-NPs in various solvents. We employed various polar and nonpolar organic solvents such as ethanol, DMSO, DMF, dioxane, acetonitrile, chloroform, carbon tetrachloride, benzene, and hexane. Because of their different surface functional groups, they make hydrogen bond with Si-NPs and altered the luminescence efficiency of the nanomaterials. Different parameters including absorption coefficient, reflectance, reflective index, dielectric constant, optical conductivity, and energy band gap were applied to investigate the optical behavior of Si-NPs in various solvents.

2. Experimental Details

2.1. Material. Silicon wafers (SUMCO Corporation, Japan), methanol (99.7%, Sigma-Aldrich, USA), ethanol (95%, Sigma-Aldrich, USA), acetonitrile (99.8%, Sigma-Aldrich, USA), chloroform (E-Merck, Germany), carbon tetrachloride (Qualikems, India), isopropanol (Panreac Quimica Co., Spain), benzene (E-Merck, Germany), dioxane (Fisher Scientific Co., UK), hexane (99.9%, Avonchem, UK), hydrofluoric acid (THF, Panreac Quimica Co., Spain), tetrahydrofuran (THF) (Nexgen Chemicals, India), hydrogen peroxide (H₂O₂) (Avonchem, UK), dimethyl sulfoxide (DMSO) (99% Fluka Chemika, USA), dimethylformamide (DMF) (99.8%, Panreac Quimica Co., Spain), chloroplatinic solution, and distilled water (DI) were of analytical grade and used directly as received without any further purification.

2.2. Synthesis of Si-NPs. Silicon NPs were prepared by chemical etching method based according to the published literature reports [2, 20]. This technique passes through two main steps, namely, the catalyst step and etchant step. In a typical method, Si wafer is cut into pieces typically of about 1 × 3 cm in dimension, which were ultrasonically cleaned with acetone prior to drying using nitrogen gas. After that, the wafer was treated in a mixture of 13.5 DI, 5 mL HF, and 1.5 mL of chloroplatinic solution in polypropylene tank for specified time as follows: 15 min, 12 min, 10 min, 8 min, and 6 min to deposit a platinum catalyst. The samples were then rinsed with H₂O and dried in blowing N₂ gas. Wafers were transferred into the etchant tank straight away. Etchant solution was prepared using the 10 mL methanol, 5 mL HF, and 10 mL H₂O₂. The wafer will usually bubble if the etching was working. The etched wafers were rinsed then in isopropanol each time and dried slowly with nitrogen gas. To examine if the Si-NPs were formed, the etched pieces were tested under UV light. If Si-NPs were present, wafer will glow brightly (in the dark or even in room light).

Spectrolite XX-15NF UV lamp was used as the UV light source. It has two wavelengths, one emitting long-wave UV (365 nm) and the other short-wavelength UV (254 nm). Then Si wafer is to be immersed into a glass bottle filled with ethane, benzene, DMSO, DMF, and hexane. The glass bottle was placed in an ultrasound bath for 4 minutes to disperse the Si-NPs. After that, wafers were pulled out and the solution that occurred was loaded with Si-NPs. The differences between the blank solution and Si-NP-dispersed solution were examined by UV light source in a dark room. The obtained NPs were centrifuged and washed for further characterization. This process is considered to be a complete one round of etching. We applied several round to get the Si- NPs until Si wafer turn from mirror surface to black one after etching.

2.3. Characterization. UV/vis absorption spectra were measured using by Perkin-Elmer Lambda-40 spectrophotometer, with the sample contained in 1 cm² stopped quartz cell of 1 cm path length, in the range 190–600 nm. The emission spectra of Si-NPs were recorded on a Perkin-Elmer photoluminescence spectrophotometer equipped with a 150-W Xenon lamp as the excitation source.

3. Results and Discussion

3.1. Optical Properties of Si-NPs in Various Solvents. Optical absorption spectroscopy was employed to investigate the optical properties of synthesized Si-NPs in the UV-Vis (200–600 nm) region in different solvents after four rounds of wafer etching at room temperature. Figure 1(a) displays the absorption spectra of the as-prepared Si-NPs in different coordinating solvents such as ethanol, dimethyl sulfoxide, dimethyl formamide, dioxane, and acetonitrile. In measuring the absorption spectra of NPs in acetonitrile
and ethanol, this transition is broadened and splitted into two bands with maxima at 228 nm and 260 nm, respectively. Such splitting may be due to the crystal field effect [19]. The absorption spectra in DMSO and DMF show a broad band but in dioxane, this broad band shifted to higher wavelength. The broadening and shifting of the absorption band at lower energy (longer wavelength) are due to coordination of solvent with Si-NPs. Remarkable changes are observed in measuring the absorption spectra in noncoordinating solvents such as chloroform, carbon tetrachloride, benzene, and hexane (Figure 1(b)). It indicates the weak binding of Si-NPs with the solvent through hydrogen bonding. In comparing the spectra in different solvents, a remarkable change in band shapes of the transitions is also observed. It specifies the effect of solvent on the optical character of the small-size Si-NPs. It is concluded that the changes in band shapes offer some measure of the relative coordinating ability (complexation) of the solvent to the Si-NPs [21, 22]. Moreover, the very small difference could be related to different natures of the solvents [21]. The comparative absorption spectral analysis in various solvents is presented in Table 1. It shows that at the same quantity of wafer pieces, the correspondence peak position, band shape, and intensities are influenced based on their respective coordination nature. Variation in shape of absorption bands in different solvents is due to the nature of chemical interaction between Si NPs and solvents. However, absorption intensities are dependent on Si-NP concentration. Additionally, the absorption intensity and concentration of Si-NPs in solution may possibly depend on the cross-sectioning of the etched area on silicon wafer. The etched

![Absorption spectra](image)

**Figure 1:** Optical absorption spectra of Si-NPs in different solvents.

<table>
<thead>
<tr>
<th>Solvent</th>
<th>Polarity index</th>
<th>Absorption peak maxima</th>
<th>Absorbance</th>
<th>Emission peaks (nm)</th>
<th>Corresponding intensity</th>
</tr>
</thead>
<tbody>
<tr>
<td>Ethanol</td>
<td>5.2</td>
<td>220 nm, 260 nm</td>
<td>Strong</td>
<td>432.3</td>
<td>18,629</td>
</tr>
<tr>
<td>DMF</td>
<td>6.4</td>
<td>212 nm, 276 nm</td>
<td>Weak, Strong</td>
<td>425.2</td>
<td>6248</td>
</tr>
<tr>
<td>DMSO</td>
<td>7.2</td>
<td>272 nm</td>
<td>Strong</td>
<td>430</td>
<td>63,380</td>
</tr>
<tr>
<td>Dioxane</td>
<td>4.8</td>
<td>284 nm, 304 nm</td>
<td>Strong</td>
<td>612</td>
<td>21,464</td>
</tr>
<tr>
<td>Acetonitrile</td>
<td>5.8</td>
<td>228 nm, 260 nm</td>
<td>Strong</td>
<td>612</td>
<td>1508</td>
</tr>
<tr>
<td>Chloroform</td>
<td>4.1</td>
<td>248 nm, 260 nm, 332 nm</td>
<td>Strong, Week</td>
<td>431, 617</td>
<td>248.20, 131.18</td>
</tr>
<tr>
<td>Carbon Tetrachloride</td>
<td>1.6</td>
<td>272 nm, 284 nm</td>
<td>Strong</td>
<td>603</td>
<td>1027</td>
</tr>
<tr>
<td>Benzene</td>
<td>2.7</td>
<td>284 nm</td>
<td>Strong</td>
<td>—</td>
<td>—</td>
</tr>
<tr>
<td>Hexane</td>
<td>0</td>
<td>244 nm</td>
<td>Strong</td>
<td>402</td>
<td>358</td>
</tr>
</tbody>
</table>

**Table 1:** List of absorption peaks, emission peaks, and corresponding intensity of the Si-NPs in different solvents.
surface area may vary in wafer piece to piece because of the nonuniformity etching in HF-based etching solution. The larger etched area of wafers may produce greater quantity of particles in solvents [18].

Photoluminescence spectra were performed to investigate the luminescence properties of the as-prepared Si-NPs. The Si-NPs prepared by chemical etching method are optically characterized by suspension in various organic solvents including ethanol, DMSO, DMF, dioxane, benzene, chloroform, CCl$_4$, and hexane. The photoluminescence spectra were recorded over wide range 380–700 nm wavelengths under monitoring 355 nm excitation wavelength. In view, recorded emission spectra are recorded after 4 rounds of wafer etching in different solvents using four wafers. The observed photoluminescence spectral results measured in various solvents are summarized in Table 2. The emission spectra of Si-NPs in different solvents show a remarkable difference due to their interaction with solvents. The difference of color in various solvents can be clearly distinguished in Table 2. It is observed in Table 2 that the wavelength shifts towards a longer wavelength (red shift) when increasing polarity index and dielectric constant of solvents. The intensity of samples can be attributed to the nature of chemical interaction between the Si-NPs and solvent. The emission peak maximum in acetonitrile is observed at 612 nm (Figure 2(a)). The emission peak position in CCl$_4$ is shifted to a lower wavelength in respect to acetonitrile; it suggests that CCl$_4$ does not interfere in silicon structure whereas acetonitrile interacted with the Si-NPs; therefore, it is shifted at a longer wavelength Figure 2(b). The emission peak positions and peak maxima of the Si-NPs in different solvents are listed in Table 1, where each sample was obtained by etching of 4 wafer pieces and was exposed to 355 nm excited emission light. It is observed that the emission peak intensity in various solvents is greatly influenced because of the solvent nature. The emission intensities of Si-NPs in solvents possibly depend on the nature of solvents and the cross-section area of etching. Higher cross-section area of etching on wafer surface can produce greater quantity of Si-NPs in solvents.

We expected that the weak emission intensity in solvents could be due to smaller dielectric constant values. Additionally, DMSO reflects high-emission intensity because of large dielectric constant values. These results are consistent with previous published reports [23]. Accordingly, the larger dielectric constant values more than 20, the Onsager length becomes of the order of the nanometer size, and no further quenching is observed. The Si-NPs in aprotic solvents show good luminescence. The possibility of high luminescent efficiency in unaprotic solvents is because they are not containing the O–H functional groups, which help in emitting light of Si-NPs in solvent with stability since aprotic solvents do not contain such functional groups. The Si-NPs exhibit good luminescence spectra in some nonpolar solvents but its stability is very limited [18]. It can be easily discerned from Figure 3 that the absorption band shape and peak maxima of Si-NPs in different solvents are increasing with polarity index and dielectric constant. The absorption peak shifts towards a longer wavelength (red shift) when increasing polarity and dielectric constant of solvents. As shown in Figures 4(a) and 4(b), the emission peak of Si-NPs in different solvents increases with increasing polarity index and dielectric constant of the solvents and shifted to a longer wavelength (red shift) or a shorter wavelength (blue shift).

### 3.2. Observed Optical Parameters

The optical absorption coefficient was calculated with the as-prepared samples.

$$\alpha = \frac{1}{L \log e} \cdot \frac{A}{e}$$

According to the absorption coefficient ($\alpha$) equation, $\alpha$ is an absorption coefficient, $A$ is for absorbance or optical density of the samples, and $L$ is thickness of the sample. The optical absorption edge was analyzed by (2). In addition, we applied Tauc formula to investigate the electronic band gap structure of the as-prepared Si-NPs, in which band gap energy ($E_g$) is determined from the energy difference between highest occupied molecular orbital and lowest occupied molecular orbitals. In measuring the $E_g$ values, we utilized the sharply

<table>
<thead>
<tr>
<th>Sample</th>
<th>Number of rounds</th>
<th>Polarity Index</th>
<th>Picture of sample under UV lamp (comparing with pure solvent)</th>
</tr>
</thead>
<tbody>
<tr>
<td>Ethyl acetate</td>
<td>4</td>
<td>4.4</td>
<td>![Image 1](Image 487x531 to 544x586)</td>
</tr>
<tr>
<td>1,2-Dichloroethane</td>
<td>4</td>
<td>3.5</td>
<td>![Image 2](Image 487x595 to 544x649)</td>
</tr>
<tr>
<td>Benzene</td>
<td>4</td>
<td>2.7</td>
<td>![Image 3](Image 487x397 to 543x453)</td>
</tr>
<tr>
<td>Toluene</td>
<td>4</td>
<td>2.4</td>
<td>![Image 4](Image 489x462 to 543x521)</td>
</tr>
<tr>
<td>Carbon tetrachloride</td>
<td>4</td>
<td>1.6</td>
<td>![Image 5](Image 489x531 to 544x586)</td>
</tr>
</tbody>
</table>
increasing absorption region of the Si-NPs for determination of optical properties and their correlation between $E_g$ and particle size of the samples. The direct band gap was calculated by plotting $(\alpha h \nu)^2$ as a function of $h \nu$ and extrapolating the linear portion of the curve to the $x$-axis. The band gap values ($E_g$) of the Si-NPs were determined by optical absorption spectra through Tauc formula [24].

$$\alpha h \nu = A (h \nu - E_g)^n,$$ \hspace{1cm} (2)

where $\alpha$ is absorbance coefficient and the exponent $n$ depends on the type of transition; $n$ may have values 1/2 and 2 corresponding to the allowed direct and allowed indirect transitions, respectively. Figure 5 shows the $E_g$ value for Si-NPs in ethanol and toluene. As observed from the absorption spectra, the absorption edge validated the direct band gap in the as-prepared samples. The $E_g$ values are obtained by extrapolating the linear portions of the plots to intercept the photon energy axis, that is, the values of the band gap $E_g$ for Si-NPs in different solvents are estimated from the intercept of the obtained straight lines at zero absorption. As shown in Figure 5, the experimentally estimated $E_g$ value of Si-NPs in ethanol and toluene is 3.52 and 3.61 eV, respectively. We expected that the increasing trend in $E_g$ value may be due to the decrease in the particle size.

Reflectance spectra were also measured for other samples by using (UV-VIS spectrophotometers) to find out some optical parameters of Si-NPs in different solvents such as refractive index and dielectric constant. The variation of reflectance ($R$) as a function of wavelength for Si-NPs in
different solvents is recorded at room temperature. The absorption coefficient, $E_g$ values, and reflectance of Si-NPs in different solvents are presented in Table 3. As observed in Table 3, the variation of absorption coefficient is depending on the nature of solvents and the solvent-solute interactions. The absorbance edge and band shapes of the spectrums are affected by the surrounding solvent environment. The absorbance increases with increasing the dielectric constant values of the reaction mixture. The reflectance values of Si-NPs in different solvents are varying because of different solvent properties, which affect the absorption edge and band shapes of the spectrum.

Figure 6 shows the correlation between polarity index and dielectric constant with emission peak. As shown in Figure 6, the absorption coefficient increases because of high polarity index of solvents.

The extinction coefficient ($K$) was obtained to measure the fraction of light lost due to scattering and absorption per unit distance of the penetration medium. The extinction coefficient is computed in the sample during the exposure of UV spectra by using the relation between % absorption and wavelength [25]. Extinction coefficient ($K$) is given by

$$K = \alpha \frac{\lambda}{4\pi},$$

where $\alpha$ is % absorption and $\lambda$ is wavelength.
Figure 7 exhibits the extinction coefficient of Si-NPs in solvents which increases with photon energy and decreases with wavelength. The extinction coefficient describes the properties of the material with respect to light of a given wavelength and indicates the absorption changes when the electromagnetic wave propagates through the material. In Figure 7, the extinction coefficient of Si-NPs in solvents has a peak at different values as seen in Table 4, which increases with increasing concentration of Si-NPs in dielectric solvent medium.

### 4. Conclusion

Si-NPs were successfully prepared by chemical etching method and suspended in various solvents to investigate the impact of solvents (DMSO, DMF, ethanol, benzene, hexane, CCl₄, chloroform, acetonitrile, etc.) on optical properties of Si-NPs. The absorption band edge and shape of band were varied causing the nature of chemical interaction between the Si-NPs and solvent. The maximum emission intensity of Si-NPs was observed in all solvents under monitoring excitation at 355 nm. Two maximum intensity emission peaks were observed located at 400 nm and 600 nm on excitation at 355 nm; the observed emission band shifting is due to the nature of solvent and etched cross-section area of the surface. Solvents have shown considerable effects on the emission wavelengths. Optical parameters such as absorption coefficient, absorption edge, transmittance, reflectance, extinction coefficient, and dielectric constant suggested the impact of solvent on the optical behavior of the Si-NPs. The nature of solvent and their interaction with Si-NPs in influenced the optical parameters and emission intensity. The increase in $E_g$ values is directly related to the decrease particle size, which is directly dependent on Si-NP size and the polarity of the solvent. The emission and absorption properties of Si-NPs were tuned by altering the environment (solvents) through electrostatic interaction of various organic solvents with the Si-NPs. The band shapes of the Si-NPs show remarkable changes in passing from noncoordinating solvent (chloroform) to various coordinating solvents, which is the result of change in the environment around Si-NPs in various solutions.
The maximum and minimum values of the extinction coefficient at the band gap region of Si-NPs in different solvents.

<table>
<thead>
<tr>
<th>Solvents</th>
<th>$k_{\text{max}}$</th>
<th>$\lambda$ (nm)</th>
<th>$h\nu$ (eV)</th>
<th>$k_{\text{min}}$</th>
<th>$\lambda$ (nm)</th>
<th>$h\nu$ (eV)</th>
<th>$k$ $10^{-7}$</th>
<th>$\lambda$ (nm)</th>
<th>$h\nu$ (eV)</th>
</tr>
</thead>
<tbody>
<tr>
<td>DMSO</td>
<td>46.97</td>
<td>272</td>
<td>4.56</td>
<td>8.75</td>
<td>216</td>
<td>5.74</td>
<td>13.90</td>
<td>456</td>
<td>2.72</td>
</tr>
<tr>
<td>DMF</td>
<td>49.20</td>
<td>600</td>
<td>2.10</td>
<td>15.9</td>
<td>192</td>
<td>6.46</td>
<td>45.95</td>
<td>552</td>
<td>2.25</td>
</tr>
<tr>
<td>Acetonitrile</td>
<td>37.70</td>
<td>228</td>
<td>5.44</td>
<td>0.68</td>
<td>500</td>
<td>2.48</td>
<td>1.64</td>
<td>368</td>
<td>3.37</td>
</tr>
<tr>
<td>Ethanol</td>
<td>34.45</td>
<td>220</td>
<td>5.64</td>
<td>3.41</td>
<td>416</td>
<td>2.98</td>
<td>4.82</td>
<td>352</td>
<td>3.52</td>
</tr>
<tr>
<td>Dioxane</td>
<td>40.80</td>
<td>284</td>
<td>4.37</td>
<td>3.03</td>
<td>216</td>
<td>5.74</td>
<td>7.83</td>
<td>380</td>
<td>3.26</td>
</tr>
<tr>
<td>Ethyl acetate</td>
<td>13.61</td>
<td>256</td>
<td>4.85</td>
<td>3.41</td>
<td>204</td>
<td>6.10</td>
<td>14.4</td>
<td>492</td>
<td>2.52</td>
</tr>
<tr>
<td>Chloroform</td>
<td>35.90</td>
<td>248</td>
<td>5.00</td>
<td>0.33</td>
<td>584</td>
<td>2.21</td>
<td>1.57</td>
<td>420</td>
<td>2.95</td>
</tr>
<tr>
<td>THF</td>
<td>42.16</td>
<td>280</td>
<td>4.43</td>
<td>2.31</td>
<td>236</td>
<td>5.26</td>
<td>22.45</td>
<td>316</td>
<td>3.93</td>
</tr>
<tr>
<td>1,2-Dichloroethane</td>
<td>34.17</td>
<td>288</td>
<td>4.31</td>
<td>0.91</td>
<td>188</td>
<td>6.60</td>
<td>9.69</td>
<td>376</td>
<td>3.29</td>
</tr>
<tr>
<td>Benzoene</td>
<td>28.18</td>
<td>284</td>
<td>4.37</td>
<td>0.00</td>
<td>388</td>
<td>3.20</td>
<td>0.42</td>
<td>328</td>
<td>3.78</td>
</tr>
<tr>
<td>Toluene</td>
<td>27.73</td>
<td>288</td>
<td>4.31</td>
<td>1.23</td>
<td>228</td>
<td>5.44</td>
<td>4.30</td>
<td>344</td>
<td>3.61</td>
</tr>
<tr>
<td>Carbon tetrachloride</td>
<td>51.86</td>
<td>272</td>
<td>4.56</td>
<td>7.98</td>
<td>244</td>
<td>5.08</td>
<td>29.44</td>
<td>352</td>
<td>3.52</td>
</tr>
<tr>
<td>Trichloroethylene</td>
<td>20.16</td>
<td>284</td>
<td>4.37</td>
<td>0.00</td>
<td>600</td>
<td>2.07</td>
<td>3.37</td>
<td>356</td>
<td>3.49</td>
</tr>
<tr>
<td>Hexane</td>
<td>39.92</td>
<td>244</td>
<td>5.08</td>
<td>0.22</td>
<td>340</td>
<td>3.65</td>
<td>1.22</td>
<td>348</td>
<td>3.56</td>
</tr>
</tbody>
</table>

**Figure 7:** The photon energy dependence of extinction coefficient of Si-NPs in (a) DMSO, (b) ethanol, (c) benzene, and (d) toluene.
Conflicts of Interest
The authors declare that they have no conflicts of interest.

Acknowledgments
The authors would like to thank the Deanship of Scientific Research, College of Science King Saud University for funding this work.

References


Submit your manuscripts at
www.hindawi.com